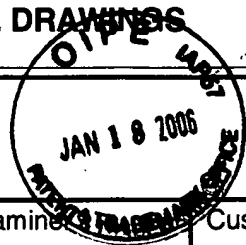


*Jan*

**TRANSMITTAL OF FORMAL DRAWINGS**

Docket No.  
**FIS920030115US1 (16506)**

Inventor: Application Of: **Omer H. Dokumaci et al.**



Application No.	Filing Date	Examiner	Customer No.	Group Art Unit	Confirmation No.
10/696,686	October 28, 2003	Jennifer M. Dolan	23389	2813	5262

Invention: **NANOCIRCUIT AND SELF-CORRECTING ETCHING METHOD FOR FABRICATING SAME**

Address to:  
**Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450**

Transmitted herewith are:

**10** sheets of formal drawing(s) for this application.

☒ Each sheet of drawing indicates the identifying indicia suggested in 37 CFR Section 1.84(c).

  
Signature

**Leslie S. Szivos, Ph.D.  
Registration No. 39,394  
SCULLY, SCOTT, MURPHY & PRESSER, P.C.  
400 Garden City Plaza - Suite 300  
Garden City, New York 11530**

**Dated: January 13, 2006**

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to "Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450" [37 CFR 1.8(a)] on

**January 13, 2006**

(Date)

  
Signature of Person Mailing Correspondence

**Leslie S. Szivos, Ph.D.**

Typed or Printed Name of Person Mailing Correspondence